

PATENT
0171-1098PUS1

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant: Takeru WATANABE, et al.
Appl. No.: NEW Group:
Filed: May 20, 2004 Examiner:
For: BASIC COMPOUND, RESIST COMPOSITION AND
PATTERNING PROCESS

INFORMATION DISCLOSURE STATEMENT
(SUBMISSION CONCURRENT WITH THE
FILING OF A NEW PATENT APPLICATION)

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

May 20, 2004

Sir:

Pursuant to 37 C.F.R. §§ 1.97 and 1.98, applicant(s) hereby submit(s) an Information Disclosure Statement for consideration by the Examiner.

I. LIST OF PATENTS, PUBLICATIONS OR OTHER INFORMATION

The patents, publications, or other information submitted for consideration by the Office are listed on PTO-1449, attached hereto.

II. COPIES

a. This application was filed before June 30, 2003. Accordingly, submitted herewith is a legible copy of (i) each U.S. and foreign patent; (ii) each publication or that portion which caused it to be listed; and (iii) all other information or that portion which caused it to be listed.

b. This application was filed on or after June 30, 2003. Accordingly, copies of cited US patents and patent application publications therefore are not included. Copies of foreign patent documents and non-patent literature are included.

c. This application is a National Phase of a PCT application. Some or all of the documents listed on the PTO-1449 are not enclosed because they were cited in the International Search Report and copies should be forwarded from the International Search Authority. If copies are needed, please contact the undersigned.

III. CONCISE EXPLANATION OF THE RELEVANCE
(check at least one box)

a. **DOCUMENTS IN THE ENGLISH LANGUAGE**

The patents, publications, or other information listed on the attached PTO 1449 are in the English language and therefore, do not require a statement of relevancy.

b. **DOCUMENTS NOT IN THE ENGLISH LANGUAGE**

A concise explanation of the relevance of all patents, publications, or other information listed that is not in the English language is as follows:

The relevancy of the foreign language documents can be determined from a review of the English language Abstracts Attached thereto.

c. **ENGLISH LANGUAGE SEARCH REPORT**

An English language version of the search report or action that indicates the degree of relevance found by the foreign office is attached, thereby satisfying the requirement for a concise explanation. See MPEP 609(III)(A)(3).

d. **OTHER**

The following additional information is provided for the Examiner's consideration.

JP 6-194834 Corresponds to US 5,691,100; JP 6-242605 Corresponds to US 5,525,453 and US 5,843,319; JP 6-242606 Corresponds to US 5,525,453 and US 5,843,319; JP 6-263716 Corresponds to US 5,612,169; JP 6-263717 Corresponds to US 5,442,087 and US 5,529,886; JP 6-266111 Corresponds to US 6,703,181; and JP 7-134419 Corresponds to US 5,658,706 and US 5,744,281

FEES

This Information Disclosure Statement is being filed concurrently with the filing of a new patent application; therefore, no fee is required.

If the Examiner has any questions concerning this IDS, he/she is requested to contact the undersigned. If it is determined that this IDS has been filed under the wrong rule, the PTO is requested to consider this IDS under the proper rule and charge the appropriate fee to Deposit Account No. 02-2448.

If necessary, the Commissioner is hereby authorized in this, concurrent, and future replies, to charge payment or credit any overpayment to Deposit Account No. 02-2448 for any additional fees required under 37 C.F.R. § 1.16 or under § 1.17; particularly, extension of time fees.

Respectfully submitted,

BIRCH, STEWART, KOLASCH & BIRCH, LLP


By _____
Gerald M. Murphy, Jr., #28,977

GMM/sm
0171-1098PUS1

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Attachment(s) : Form PTO-1449(s)
 Documents
 Foreign Search Report
 Fee
 Other: _____

(Rev. 02/12/2004)

Form PTO-1449

**INFORMATION DISCLOSURE CITATION
IN AN APPLICATION**

(Use several sheets if necessary)

ATTY. DOCKET NO.
0171-1098PUS1APPLICATION NO.
NEWAPPLICANT
Takeru WATANABE, et al.FILING DATE
May 20, 2004

GROUP

U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	KIND	DATE	NAME	CLASS	SUB CLASS	FILING DATE IF APPROPRIATE
	US 5,691,100	A	1997-11-25	Kudo, et al.			
	US 5,525,453	A	1996-06-11	Przybilla, et al.			
	US 5,843,319	A	1998-12-01	Przybilla, et al.			
	US 5,612,169	A	1997-03-18	Eichhorn, et al.			
	US 5,529,886	A	1996-06-25	Eichhorn, et al.			
	US 5,442,087	A	1995-08-15	Eichhorn, et al.			
	US 6,703,181	B1	2004-03-09	Hayashi, et al.			
	US 5,658,706	A	1997-08-19	Niki, et al.			
	US 5,744,281	A	1998-04-28	Niki, et al.			
	US 6,004,724	A	1999-12-21	Yamato, et al.			

FOREIGN PATENT DOCUMENTS

Office	DOCUMENT NUMBER	Kind	DATE	COUNTRY	CLASS	SUB CLASS	TRANSLATION	
							YES	NO
JP	2-27660	B2	1990-06-19	JAPAN			ABS	
JP	63-27829	A	1988-02-05	JAPAN			ABS	
JP	5-232706	A	1993-09-10	JAPAN			ABS	
JP	5-249683	A	1993-09-28	JAPAN			ABS	
JP	5-158239	A	1993-06-25	JAPAN			ABS	
JP	5-249662	A	1993-09-28	JAPAN			ABS	
JP	5-257282	A	1993-10-08	JAPAN			ABS	
JP	5-289322	A	1993-11-05	JAPAN			ABS	
JP	5-289340	A	1993-11-05	JAPAN			ABS	

OTHER DOCUMENTS (Include Name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.) date, page(s), volume-issue number(s), publisher, city and/or country where published.)

HINSBERG et al., "Fundamental studies of airborne chemical contamination of chemically amplified resists", Journal of Photopolymer Science and Technology, Vol. 6, No. 4, 1993, 535-546.

KUMADA et al., "Study on over-top coating of positive chemical amplification resists for KrF excimer laser lithography", Journal of Photopolymer Science and Technology, Vol. 6, No. 4, 1993, 571-574.

HATAKEYAMA et al., "Investigation of discrimination enhancement with new modeling for poly-hydroxystyrene positive resists", Journal of Photopolymer Science and Technology, Vol. 13, No. 4, 2000, 519-524.

EXAMINER

DATE CONSIDERED

EXAMINER: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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Form PTO-1449 INFORMATION DISCLOSURE CITATION IN AN APPLICATION (Use several sheets if necessary)				ATTY. DOCKET NO. 0171-1098PUS1	APPLICATION NO. NEW		
				APPLICANT Takeru WATANABE, et al.			
				FILING DATE May 20, 2004	GROUP		
U.S. PATENT DOCUMENTS							
EXAMINER INITIAL	DOCUMENT NUMBER	Kind	DATE	NAME	CLASS	SUB CLASS	FILING DATE IF APPROPRIATE
	US 6,261,738	B1	2001-07-17	Asakura, et al.			
	US						
	US						
FOREIGN PATENT DOCUMENTS							
Office	DOCUMENT NUMBER	Kind	DATE	COUNTRY	CLASS	SUB CLASS	TRANSLATION
							YES
JP	6-194834	A	1994-07-15	JAPAN			ABS
JP	6-242605	A	1994-09-02	JAPAN			ABS
JP	6-242606	A	1994-09-02	JAPAN			ABS
JP	6-263716	A	1994-09-20	JAPAN			ABS
JP	6-263717	A	1994-09-20	JAPAN			ABS
JP	6-266100	A	1994-09-22	JAPAN			ABS
JP	6-266111	A	1994-09-22	JAPAN			ABS
JP	7-128859	A	1995-05-19	JAPAN			ABS
JP	7-92678	A	1995-04-07	JAPAN			ABS
JP	7-92680	A	1995-04-07	JAPAN			ABS
JP	7-92681	A	1995-04-07	JAPAN			ABS
JP	7-120929	A	1995-05-12	JAPAN			ABS
JP	7-134419	A	1995-05-23	JAPAN			ABS
JP	2000-314956	A	2000-11-14	JAPAN			ABS
JP	9-95479	A	1997-04-08	JAPAN			ABS
JP	9-230588	A	1997-09-05	JAPAN			ABS
JP	9-208554	A	1997-08-12	JAPAN			ABS
OTHER DOCUMENTS (Include Name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.) date, page(s), volume-issue number(s), publisher, city and/or country where published.)							
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